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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
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7590	02/08/2006		EXAMINER	
Farzad E Amini Blakely Sokoloff Taylor & Zafman LLP 12400 WILSHIRE BOULEVARD SEVENTH FLOOR LOS ANGELES, CA 90025			HENN, TIMOTHY J	
			ART UNIT	PAPER NUMBER
			2612	

DATE MAILED: 02/08/2006

Please find below and/or attached an Office communication concerning this application or proceeding.

Office Action Summary	Application No.	Applicant(s)	
	09/475,487	ASSADI, AZAR	
	Examiner Timothy J. Henn	Art Unit 2612	

-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --
Period for Reply

A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) OR THIRTY (30) DAYS, WHICHEVER IS LONGER, FROM THE MAILING DATE OF THIS COMMUNICATION.

- Extensions of time may be available under the provisions of 37 CFR 1.136(a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication.
- If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication.
- Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b).

Status

1) Responsive to communication(s) filed on 05 December 2005.
 2a) This action is FINAL. 2b) This action is non-final.
 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under *Ex parte Quayle*, 1935 C.D. 11, 453 O.G. 213.

Disposition of Claims

4) Claim(s) 1-8, 13-21 and 23-26 is/are pending in the application.
 4a) Of the above claim(s) _____ is/are withdrawn from consideration.
 5) Claim(s) _____ is/are allowed.
 6) Claim(s) 1-8, 13-21 and 23-26 is/are rejected.
 7) Claim(s) _____ is/are objected to.
 8) Claim(s) _____ are subject to restriction and/or election requirement.

Application Papers

9) The specification is objected to by the Examiner.
 10) The drawing(s) filed on 30 December 1999 is/are: a) accepted or b) objected to by the Examiner.
 Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).
 Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d).
 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152.

Priority under 35 U.S.C. § 119

12) Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
 a) All b) Some * c) None of:
 1. Certified copies of the priority documents have been received.
 2. Certified copies of the priority documents have been received in Application No. _____.
 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)).

* See the attached detailed Office action for a list of the certified copies not received.

Attachment(s)

1) <input checked="" type="checkbox"/> Notice of References Cited (PTO-892)	4) <input type="checkbox"/> Interview Summary (PTO-413)
2) <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)	Paper No(s)/Mail Date. _____
3) <input type="checkbox"/> Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date _____	5) <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)
	6) <input type="checkbox"/> Other: _____

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

1. A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on 05 December 2005 has been entered.

Response to Arguments

2. Applicant's arguments filed 05 December 2005 have been fully considered but they are not persuasive. Regarding Applicant's arguments that Gal does not disclose the use of the grating without the lens the examiner notes that the claims as written do not require a diffraction grating without the use of a microlens. Since Gal discloses the use of diffraction gratings, the limitation of the claims is met even though Gal further discloses the use of a microlens. The examiner further notes that Gal specifically discloses the use of the color separation microlens with an image sensor (c. 2, ll. 1-7).

Applicant further argues that the combination does not disclose a protective layer placed between the gratings and on top of the transparent conductor. The examiner notes that, as broadly as claimed, the antireflection film of Kato meets this limitation. While the coating of Kato is admittedly not in the same location as depicted in Figure 1 of the application, it can be said to be on top of (e.g. above) the transparent conductor

and between the diffraction gratings (e.g. the coating 8 in Figure 11 is between the upper most grating of item 7 and the upper most grating of the next grating to the left).

If the claims were amended to specify that the protective layer is in contact with the transparent conductor and covers the section of the transparent conductor which is not covered by the diffraction gratings as depicted in Figure 1 of the application, this interpretation of the claims would no longer be valid.

Applicant further argues that the antireflection film of Kato is not disclosed as being scratch resistant, however the claims do not require the protective layer to be scratch resistant.

Applicant further argues that Rostoker discloses the use of lenses and not diffraction gratings as claimed. However, Rostoker in column 6, lines 1-12 that the lens elements 108 are preferably formed as diffractive binary optical structures.

Therefore the Applicant's arguments are not considered persuasive and the previous rejections will be maintained. If the Applicant has any questions concerning the suggestions made by the examiner, the Applicant is invited to contact the examiner at the number listed at the end of this official action.

Drawings

3. New corrected drawings in compliance with 37 CFR 1.121(d) are required in this application because the drawings contain handwritten labels which are difficult to read. Applicant is advised to employ the services of a competent patent draftsperson outside the Office, as the U.S. Patent and Trademark Office no longer prepares new drawings.

The corrected drawings are required in reply to the Office action to avoid abandonment of the application. The requirement for corrected drawings will not be held in abeyance.

Claim Objections

4. Claims 1-8 and 13-16 are objected to because of the following informalities:

Claims 1-8 and 13-16 claim a set of light sensitive diodes, an n-layer placed on top of each of the light sensitive diodes; an i-layer placed on top of the n-layer; a p-layer placed on top of the i-layer and a transparent conductor placed on top of the p-layer. However, the n-layer, i-layer and p-layer make up the light sensitive diodes of Applicant's invention (see Figure 1). As currently written, the claims require two sets of diodes, one on top of the other, which is not disclosed in the application. Appropriate correction is required.

Claim Rejections - 35 USC § 103

5. The text of those sections of Title 35, U.S. Code not included in this action can be found in a prior Office action.

6. Claims 1-8 and 13-16 are rejected under 35 U.S.C. 103(a) as being unpatentable over Thiel et al. (US 6,114,739) in view of Gal et al. (US 5,600,486) in view of Kato et al. (US 2002/0030890) in view of Ikemori et al. (US 5,976,680).

[claim 1]

Regarding claim 1, Thiel discloses a set of light sensitive diodes including a transparent conductor (Figure 2, Item 50), the set of light sensitive diodes including an

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n-layer (Figure 2, Item 44); an i-layer (Figure 2, Item 46) and a p-layer (Figure 2, Item 48). However, Thiel does not disclose a set of separated echelon diffraction grating elements for producing complementary colors.

Gal discloses the use of echelon diffraction grating elements placed above an image sensor (Figure 2). Gal discloses the use of these diffraction gratings to separate light into color spots for a camera on a chip (c. 2, ll. 1-7). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include the protective layer of Gal in the camera of Thiel to separate light into its respective colors for creation of color images. However, Thiel in view of Gal does not specifically disclose the use of three or more light sensitive diodes. Official Notice is taken that it is well known in the art to use many more than three light sensitive diodes in a color camera device in order to take high resolution pictures. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use more than three diodes to capture high resolution pictures. However, Thiel in view of Gal does not disclose a protective layer placed above the transparent conductor and disposed between adjacent echelon diffraction gratings.

Kato discloses that by placing antireflection coatings on a diffractive optical element the diffraction efficiency of the optical element can be improved (Figure 11; Paragraphs 0082-0083). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include an antireflection coating above the echelon diffraction grating elements of Thiel in view of Gal to improve the devices diffraction efficiency. The examiner notes that by placing an antireflection coating on

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the echelon diffraction gratings of Thiel in view of Gal, they would necessarily be above the transparent conductor 50 and between adjacent echelon grating elements as claimed. However, Thiel in view of Gal in view of Kato does not disclose a protective layer which is of a sol-gel material.

Ikemori teaches a non-fogging antireflection film which is insoluble, wear resistant and weatherable (abstract) which is made using a sol-gel process (c. 5, ll. 41-55). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use the antireflection film of Ikemori which is made out of a sol-gel process and which is insoluble, wear resistant, weatherable and non-fogging.

[claim 2]

Regarding claim 2, see claim 1.

[claim 3]

Regarding claim 3, Thiel discloses an image sensor that is compatible with a metal oxide semiconductor (MOS) fabrication process and which generates charges representative of the intensity of incident light (c. 3, ll. 27-36). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use materials which are compatible with MOS fabrication processes for construction of the echelon diffraction gratings of Gal and the antireflection coating of Kato.

[claim 4]

Regarding claim 4, Gal discloses the use of four step echelon grating elements in Figures 14-18.

[claim 5]

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Regarding claim 8, Thiel discloses an integrated pixel sensor structure having: a set of light sensitive diodes including a transparent conductor (Figure 2, Item 50), the set of light sensitive diodes including an n-layer (Figure 2, Item 44); an i-layer (Figure 2, Item 46) and a p-layer (Figure 2, Item 48) and a post capture signal processing circuit coupled to the integrated pixel sensor (c. 3, II. 2-10). However, Thiel does not disclose a set of echelon diffraction grating elements for producing complementary colors.

Gal discloses the use of echelon diffraction grating elements placed above an image sensor (Figure 2). Gal discloses the use of these diffraction gratings to separate light into color spots for a camera on a chip (c. 2, II. 1-7). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include the protective layer of Gal in the camera of Thiel to separate light into its respective colors for creation of color images. However, Thiel in view of Gal does not specifically disclose the use of three or more light sensitive diodes. Official Notice is taken that it is well known in the art to use many more than three light sensitive diodes in a color camera device in order to take high resolution pictures. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use more than three diodes to capture high resolution pictures. However, Thiel in view of Gal does not disclose a protective layer placed above the transparent conductor and disposed between adjacent echelon diffraction gratings.

Kato discloses that by placing antireflection coatings on a diffractive optical element the diffraction efficiency of the optical element can be improved (Figure 11; Paragraphs 0082-0083). Therefore, it would have been obvious to one of ordinary skill

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in the art at the time the invention was made to include an antireflection coating above the echelon diffraction grating elements of Thiel in view of Gal to improve the devices diffraction efficiency. The examiner notes that by placing an antireflection coating on the echelon diffraction gratings of Thiel in view of Gal, they would necessarily be above the transparent conductor 50 and between adjacent echelon grating elements as claimed. However, Thiel in view of Gal in view of Kato does not disclose a protective layer which is of a sol-gel material.

Ikemori teaches a non-fogging antireflection film which is insoluble, wear resistant and weatherable (abstract) which is made using a sol-gel process (c. 5, ll. 41-55). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use the antireflection film of Ikemori which is made out of a sol-gel process and which is insoluble, wear resistant, weatherable and non-fogging.

[claim 6]

Regarding claim 6, see claim 5.

[claim 7]

Regarding claim 7, the examiner notes that sol-gel materials are compatible with standard diode fabrication processes.

[claim 8]

Regarding claim 8, Gal discloses the use of four step echelon grating elements in Figures 14-18.

[claims 13-16]

Claims 13-16 are method claims corresponding to apparatus claims 1-4.

Therefore, claims 13-16 are analyzed and rejected as previously discussed with respect to claims 1-4.

7. Claims 17-21 and 23-26 are rejected under 35 U.S.C. 103(a) as being unpatentable over Thiel et al. (US 6,114,739) in view of Rostoker (US 5,760,834) in further view of Ikemori et al. (US 5,976,680).

[claim 17]

Regarding claim 17, Theil discloses an integrated circuit die (Figure 2) comprising: an image sensing area of the die having a plurality of light-sensitive diodes (Figure 2, Items 44, 46 and 48) formed above a metallization layer of the die (Figure 2, Items 45) and having a transparent conductor (Figure 2, Item 50). However Theil lacks a protective layer of the die and includes a plurality of echelon diffraction gratings and wherein the protective layer has a low enough deposition temperature so as not to environmentally stress the transparent conductor, and the protective layer covers a portion of the transparent layer not covered by the plurality of echelon diffraction gratings.

Rostoker teaches that by placing elements including a LCD panel (Figure 16B, Item 1630) and a binary optic element or "diffraction grating element" (Figure 16B, Item 1610) over an image sensing array (Figure 16B, Item 1620) a sandwiched display/image sensor (c. 13, II. 40-65; c. 14, II. 23-39) capable of color imaging (c. 10, II. 9-43) is formed. The examiner notes that Rostoker's LCD panel placed above an image

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sensing array inherently form a protective layer which covers the entire array and the set of echelon diffraction grating elements, including an area which would not be covered by the echelon diffraction grating elements as claimed. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include a "protective layer" or LCD panel and a binary optic element as taught by Rostoker to create a combination display/image sensor capable of color imaging. The examiner further notes that in order for such a device to be manufactured the protective layer must inherently have a low enough deposition temperature so as not to environmentally stress the transparent conductor. However, Thiel in view of Rostoker does not specifically disclose the use of three or more light sensitive diodes. Official Notice is taken that it is well known in the art to use many more than three light sensitive diodes in a color camera device in order to take high resolution pictures. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use more than three diodes to capture high resolution pictures. However, Thiel in view of Rostoker lacks a protective layer which is of a sol-gel material.

Official Notice is taken that the use of anti-reflection layers in image sensors is notoriously well known to improve the efficiency of the image sensors. Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to include anti-reflection properties in the protective layer of Theil in view of Rostoker to improve the efficiency of the image sensor. Ikemori teaches a non-fogging antireflection film which is insoluble, wear resistant and weatherable (abstract) which is made using a sol-gel process (c. 5, ll. 41-55). Therefore, it would have been obvious to

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one of ordinary skill in the art at the time the invention was made to use the antireflection film of Ikemori which is made out of a sol-gel process and which is insoluble, wear resistant, weatherable and non-fogging.

[claim 18]

Regarding claim 18, Thiel discloses a plurality of diodes having amorphous silicon as their photoactive material (Figure 2, Item 46).

[claim 19]

Regarding claim 19, Thiel discloses a plurality of diodes having a n-i-p structure (Figure 2, Items 44, 46 and 48).

[claim 20]

Regarding claim 20, Thiel discloses n and p layers which are thin relative to the i portion (Figure 2).

[claim 21]

Regarding claim 21, Thiel discloses a plurality of diodes having a transparent conductor made of an ITO layer that forms a top contact of the plurality of diodes (Figure 2, Item 50; c. 5, ll. 38-45).

[claim 23]

Regarding claim 23, see claim 17

[claim 24]

Regarding claim 24, Rostoker discloses a diffraction grating designed to impart RGB color sensing to the image sensing area of the die (Figure 8; c. 10, ll. 9-43).

[claim 25]

Regarding claim 25, see claim 17.

[claim 26]

Regarding claim 26, Rostoker discloses the use of imaging devices such as CCD arrays or "any other suitable device which changes state or generates a potential or potential difference upon incidence of light" (c. 5, ll. 5-26). Thiel discloses an image sensor that is compatible with a metal oxide semiconductor (MOS) fabrication process and which generates charges representative of the intensity of incident light (c. 3, ll. 27-36). Therefore, it would have been obvious to one of ordinary skill in the art at the time the invention was made to use materials which are compatible with MOS fabrication processes for construction of the protective layer of Rostoker when using "any other suitable device which changes state or generates a potential or potential difference upon incidence of light" such as MOS image sensors. The examiner further notes that sol-gel processes are compatible with MOS fabrication.

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Timothy J. Henn whose telephone number is (571) 272-7310. The examiner can normally be reached on M-F 9:00 AM - 6:00 PM.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Ngoc Yen Vu can be reached on (571) 272-7320. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

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Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see <http://pair-direct.uspto.gov>. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

TJH
2/3/2006



NGOC-VEN VU
PRIMARY EXAMINER